

Notice of References Cited		Application/Control No.	Applicant(s)/Patent Under Reexamination	
		09/499,037	AIHARA ET AL.	
Examiner		Art Unit		Page 1 of 1
Johannes P Mondt		2826		

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-			
	B	US-			
	C	US-			
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FOREIGN PATENT DOCUMENTS

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	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
*	U	Matsuhashi, H. et al., "Optimum Electrode Materials for Ta ₂ O ₅ Capacitors for High- and Low- Temperature Processes", Jpn. J Appl. Phys., Volume 53, pp. 1293-1297 (1994) (made of record by Applicant in Response filed 09/22/2003)
	V	
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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